INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(use as many sheets as necessary)

Sheet 1 of

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Application Number	~~10/109,688~~ To Be Assigned
Filing Date	~~March 28, 2002~~ Concurrently herewith
First Named Inventor	Joseph M. DeSimone
Group Art Unit	~~1772~~
Examiner Name	Unknown
Attorney Docket Number	5470.351DV

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Attorney Docket Number 5470-351DV

Serial No. ~~10/109,588~~ To Be Assigned

Applicants: Joseph M. DeSimone et al;

Filing Date: concurrently herewith ~~March 28, 2002~~

Group ~~1711~~

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Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date if Appropriate

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